

Supporting Information

Highly Transparent and Flexible Biobased Polyimide/TiO₂ and ZrO₂ Hybrid Films with Tunable Refractive Index, Abbe Number, and Memory Properties

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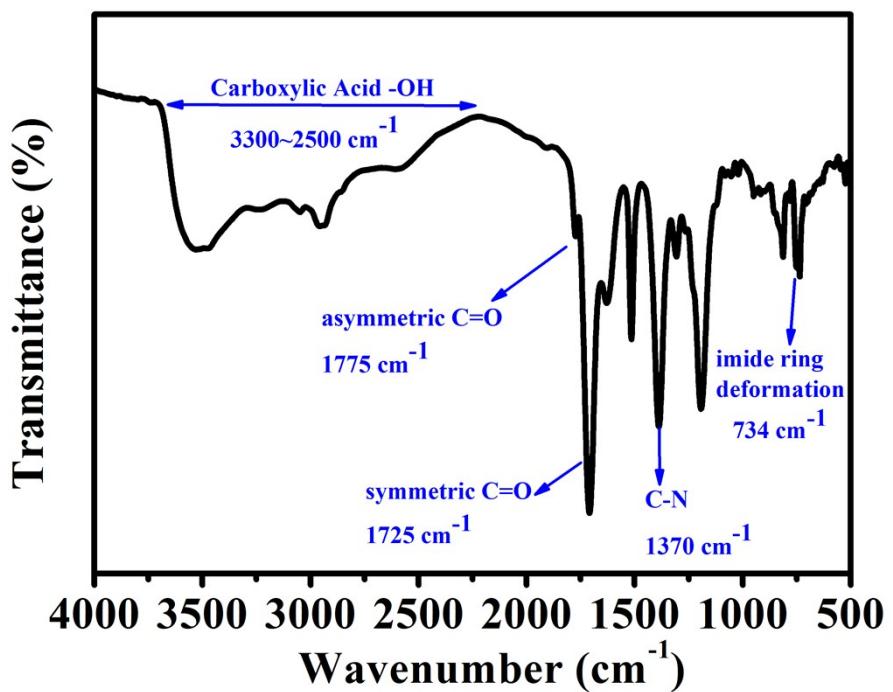


Fig. S1. IR spectrum of **4ATA-PI** film.

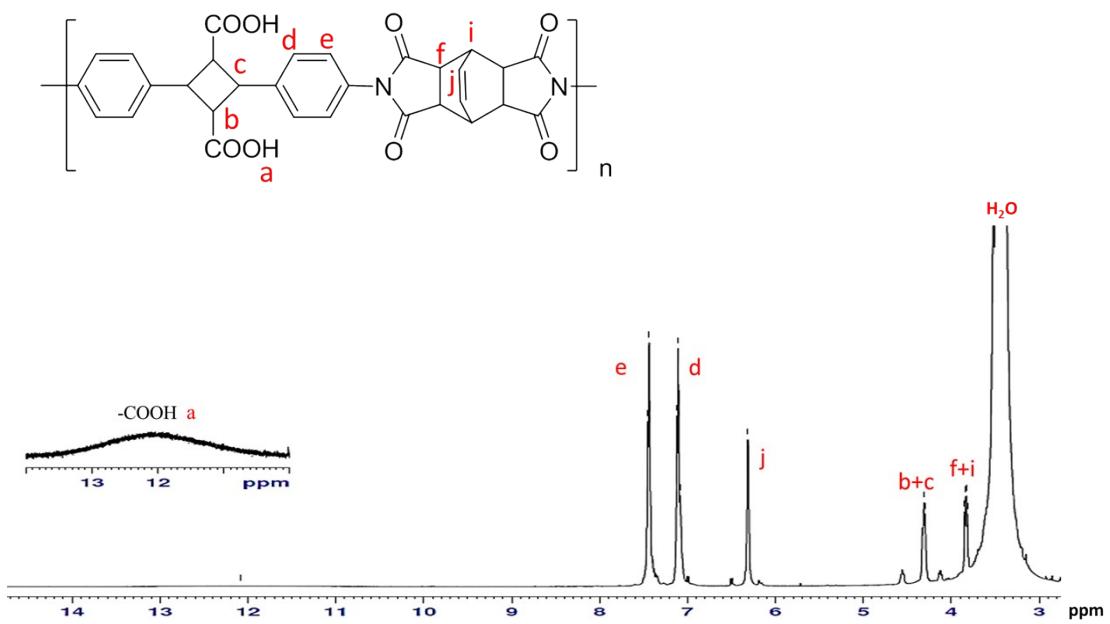


Fig. S2. ^1H NMR spectra of **4ATA-PI** in $\text{DMSO}-d_6$.

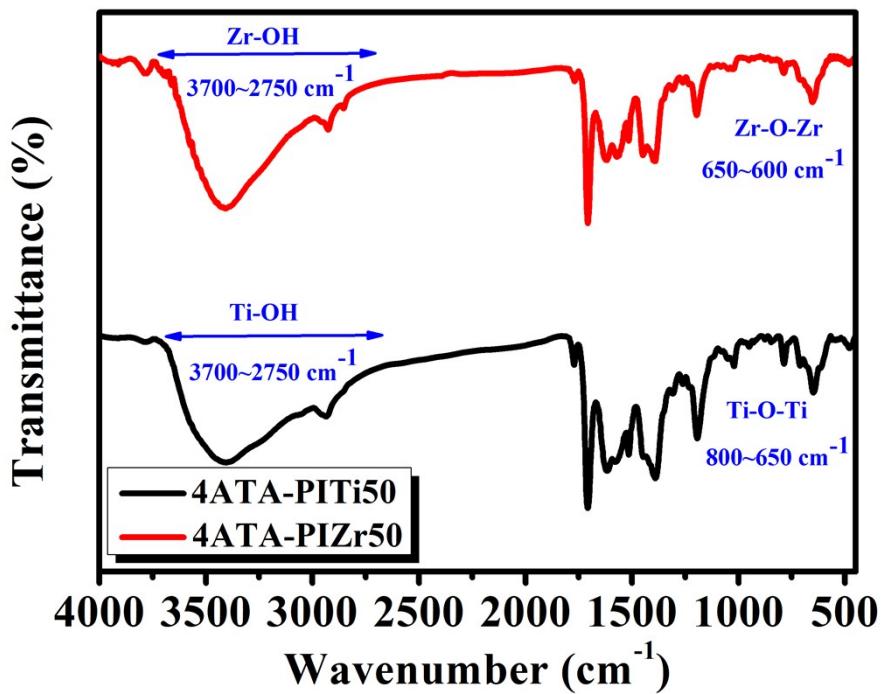


Fig. S3. IR spectra of **4ATA-PITi50** and **4ATA-PIZr50** hybrid materials.

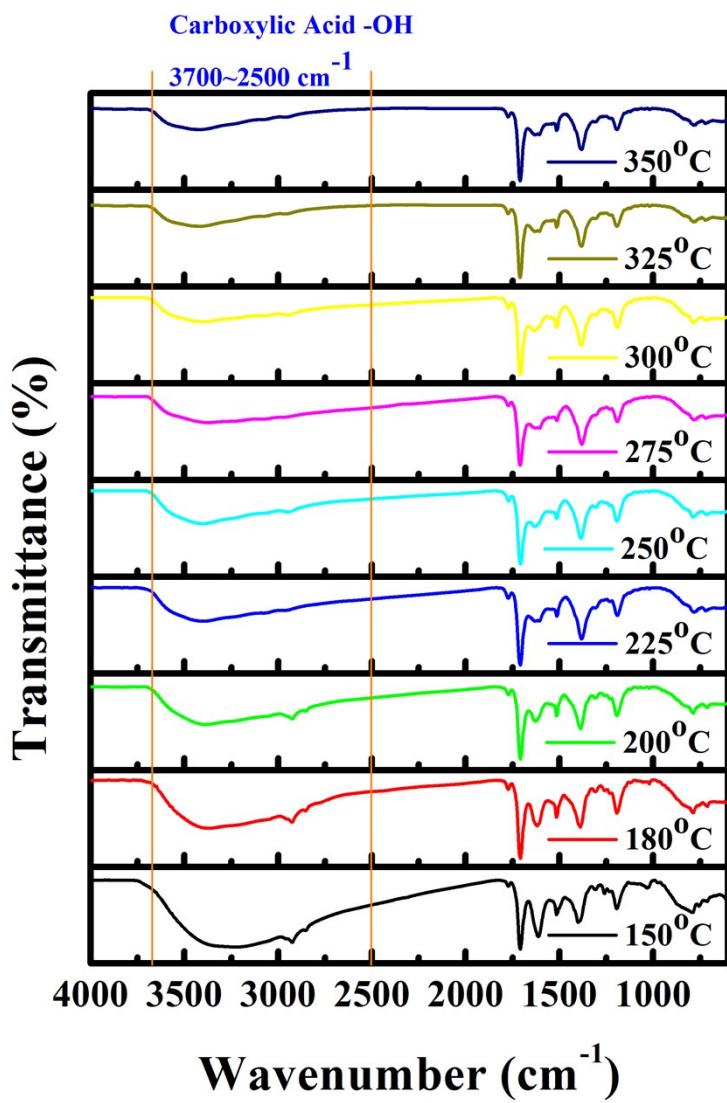


Fig. S4. IR spectrum of **4ATA-PITi30** at different curing temperatures.

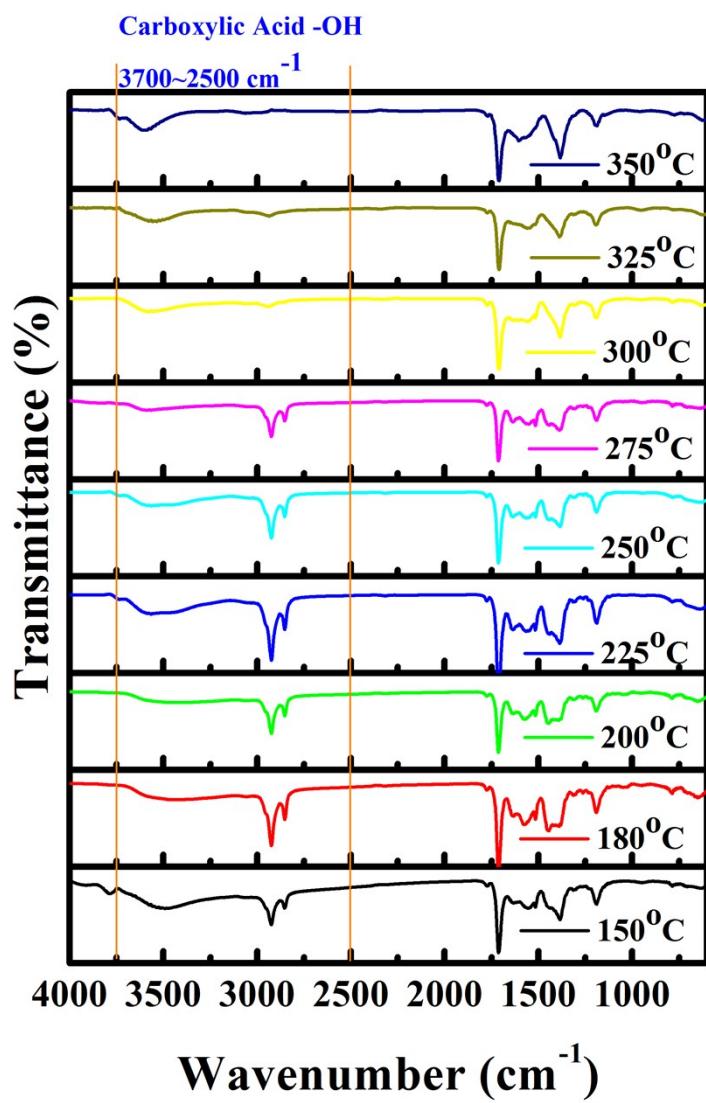


Fig. S5. IR spectrum of **4ATA-PIZr30** at different curing temperatures.

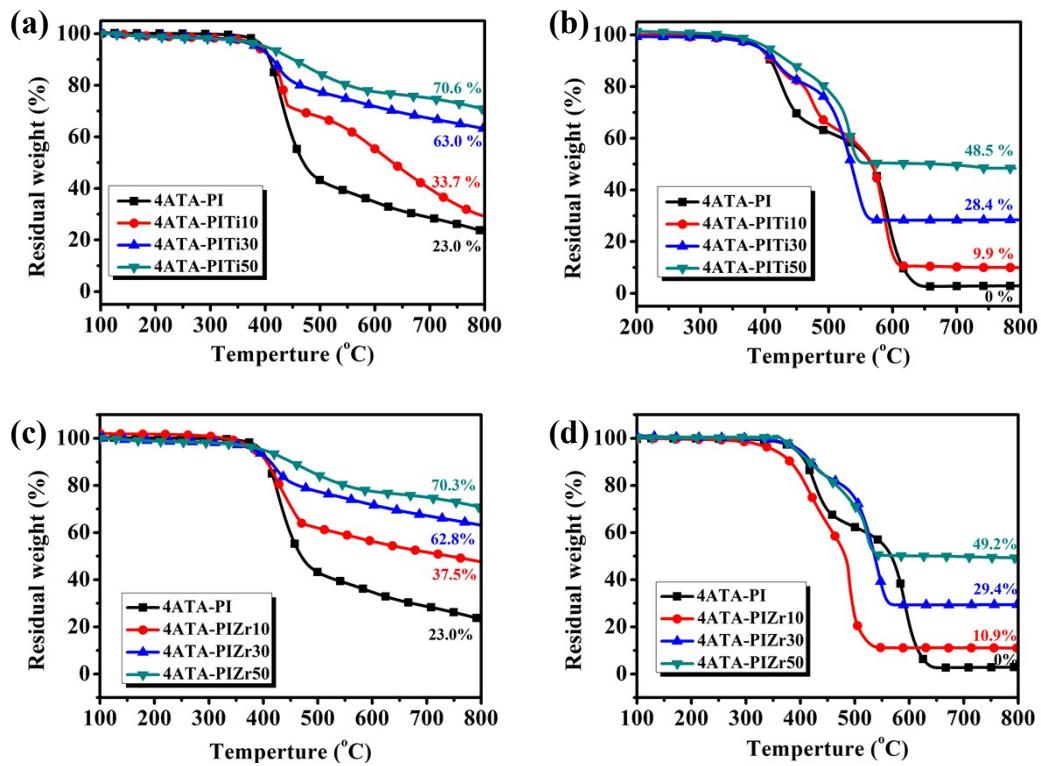


Fig. S6. TGA traces of **4ATA-PI/TiO₂** and **4ATA-PI/ZrO₂** hybrid materials (a) and (c) in N_2 , (b) and (d) in air.

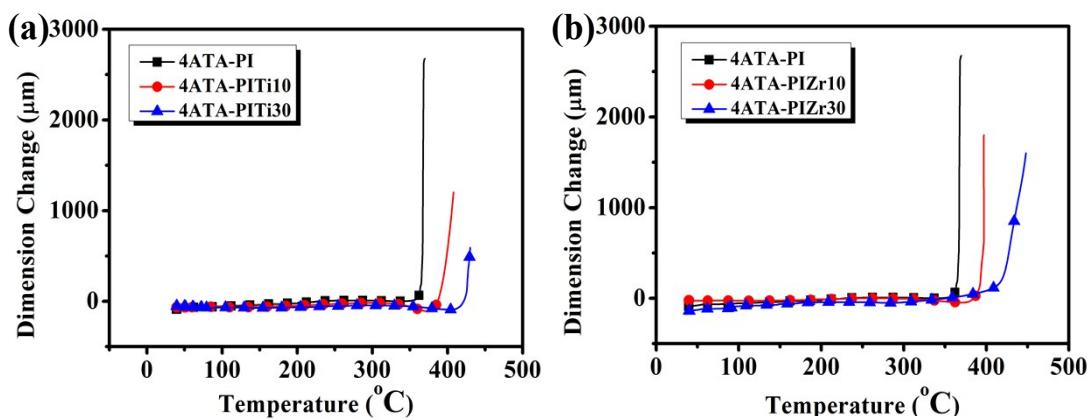


Fig. S7. TMA curves of (a) 4ATA-PI/TiO₂ and (b) 4ATA-PI/ZrO₂ hybrid films with the heating rate of 10 $^{\circ}\text{C}/\text{min}$.

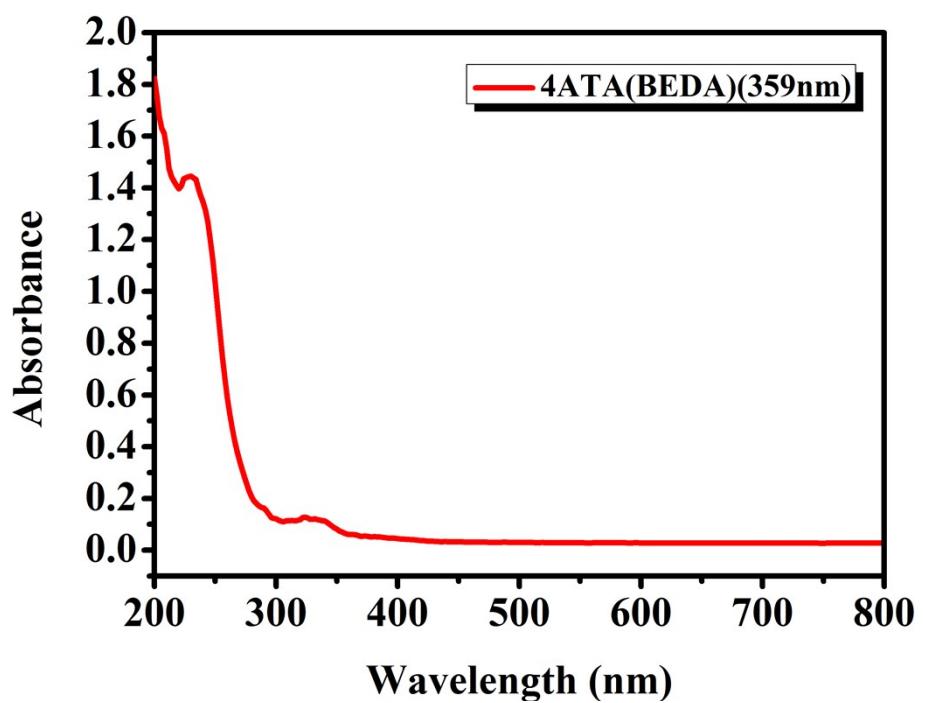


Fig. S8. UV-vis absorption spectrum of **4ATA-PI** film.

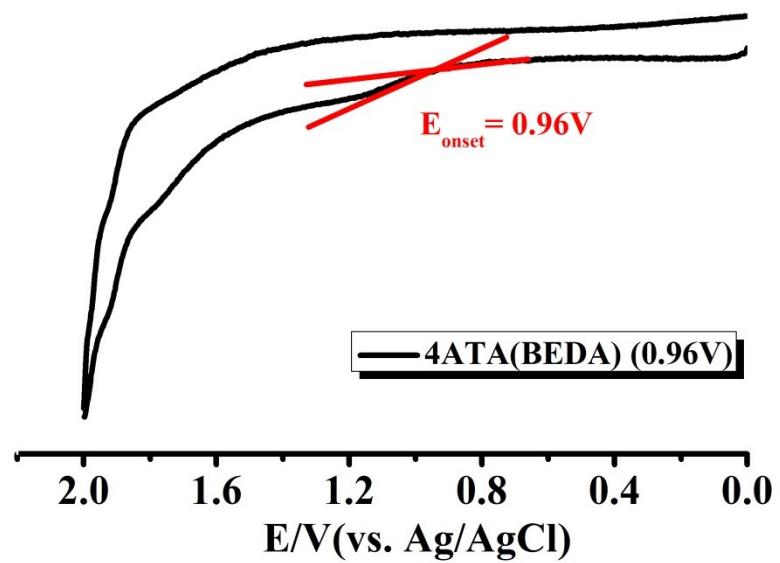


Fig. S9. Cyclic voltammetric diagram of the **4ATA-PI** film on an ITO-coated glass substrate.

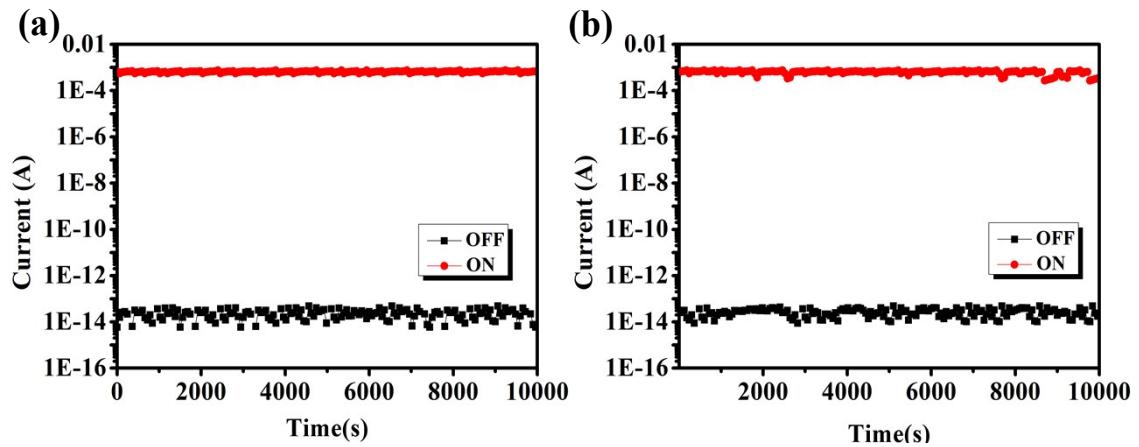


Fig. S10. The stability of memory devices in the ON and OFF states of the ITO/4ATA-PI hybrid materials ($50 \pm 3\text{nm}$)/Al devices (a) 4ATA-PITi30 and (b) 4ATA-PIZr30.